IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

DAVID F. BOCIAN, WERNER G. KUHR, JONATHAN S. LINDSEY, RAJEEVE B. DABKE, and ZHIMING LIU

Application No.: 10/040,059

Filed: 10/26/2001

For: FORMATION OF SELF-ASSEMBLED MONOLAYERS ON SILICON SUBSTRATES

Commissioner for Patents PO Box 1450

Alexandria, VA 22313-1450

Sir:

This paper is filed in response to the Office Action dated October 10, 2006 containing a Restriction Requirement. The following documents are enclosed herewith:

1) A petition to extend the period of response for one month.

Examiner: JENNIFER Y. CHO

Art Unit: 1621

Confirmation No: 9383

RESPONSE TO RESTRICTION